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Exploring the impact of the substrate in RF GaN-on-Si Technologies Nadine Collaert Demand for higher capacity continues to surge driven by exponential growth in connected devices.

Growing challenges...

- Spectrum congestion
- Bandwidth limitations
- Coverage at higher frequencies
- Energy efficiency
- Security and privacy
- Interoperability
- Scalability



https://resources.pcb.cadence.com/blog/2023-terahertz-communication-for-a-6g-future

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Challenges from baseband to antenna to tackle higher frequencies



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GaN is the champion in delivering power



GaN-on-Si is the most cost-efficient and scalable flavor of GaN



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Imec's RF GaN-on-Si platform for infra & UE



B. Parvais et al., IEDM 2020.R. ElKashlan et al., EUMW 2022.R. ElKashlan et al., IMS 2023 & 2024.

- CMOS-compatible and scalable GaN-on-Si platform
- Topics of active research:
 - Material improvement
 - Device design and scaling
 - E-mode vs. D-mode
 - Reliability
 - Thermal management
 - Impact of Si substrate

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Why are substrate losses a problem ?

The importance of substrate for RF applications



- Substrate can have a detrimental impact on:
 - Switch linearity
 - Q Factor of passives
 - PA efficiency

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Substrate RF losses in GaN-on-Si



S. Yadav et al., IEDM 2020. S. Yadav et al., ICICDT 2021. Diffusion of AI and Ga atoms at the AIN/Si interface

RF circuits suffer from a conductive substrate even with HR-Si

High conduction layer



GaN-on-Si getting closer to TR SOI target substrate performance





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Complex behavior for GaN-on-Si substrates



- P. Cardinael et al., ESSDERC 2021.
- P. Cardinael et al., IEEE Microwave and Wireless Technology Letters 2022 & 2023.
- P. Cardinael et al., J-EDS 2024.

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- Strong hysteresis observed in $\rho_{\rm eff}(V)$ for GaN-on-Si substrate
- Correlation between \(\rho_{\medgeff}(V)\) and HD(V) is not straightforward for time-dependent stacks



Porosification of the silicon substrate





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Porous silicon method to reduce losses and improve linearity

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G. Scheen et al., EuMC 2023.





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- Growing interest from industry in RF GaN-on-Si technology for both infrastructure and handset applications.
- Understanding the impact of non-idealities related to defects, thermal, substrate on RF FOM is key
- Significant progress has been made in understanding and mitigating substrate-related challenges in RF GaN-on-Si technology, paving the way for enhanced device performance and integration.



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